



HpHT HFK131 and HFK328 ELEMENTS

High pH and Temperature Cleanable Ultrafiltration Sanitary Spiral Element Series

PRODUCT DESCRIPTION

Membrane Chemistry:	Proprietary semi-permeable polyethersulfone (PES)		
Membrane Type:	HpHT HFK-131 with observed separation range of 10,000 Daltons HpHT HFK-328 with observed separation range of 5,000 Daltons		
Construction:	Sanitary spiral wound element with controlled net outer wrap		
Regulatory Status:	Compliant with US FDA CFR Title 21, EC Reg. No. 1935/2004, and EU Reg. No. 10/2011. Halal-certified by the Islamic Food and Nutrition Council of America (IFANCA).		
Options:	Diameter:	6.3", 6.4", or 8.0"	
	Outer Wrap:	Controlled or trimmable	
	Feed Spacer:	30 mil, 45 mil, 62 mil or 80 mil	

NOMINAL SPECIFICATIONS

Model	Membrane Area*							
	30-mil Spacer		45-mil Spacer		62-mil Spacer		80-mil Spacer	
	ft ²	(m ²)	ft ²	(m ²)	ft ²	(m ²)	ft ²	(m ²)
HpHT 3838 UF K328/K131	66	(6.1)	54	(5.0)	-	-	-	-
HpHT 4336 UF K328/K131	-	-	79	(7.3)	137	(12.7)	112	(10.4)
HpHT 6438 UF K328/K131	206	(19.1)	167	(15.5)	137	(12.7)	112	(10.4)
HpHT 8038 UF K328/K131	330	(30.7)	265	(24.6)	228	(21.2)	-	-

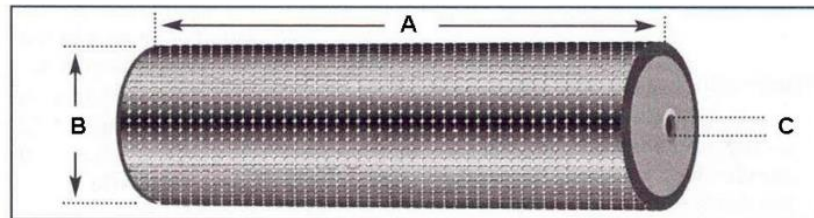
* - not all options are available

OPERATING AND DESIGN INFORMATION*

Typical Operating Pressure:	30 - 120 psi (2.1 - 8.3 bar)
Maximum Operating Pressure:	140 psi (9.7 bar)
Operating Temperature Range:	41 - 140°F (5 - 60°C)
Cleaning Temperature Range:	105 - 185°F (40 - 85°C)
Allowable pH - Continuous Operation:	2.0 - 10.0
Allowable pH - Clean-In-Place (CIP):	1.8 - 12.5
Design Pressure Drop Per Element:	30 mil: 12-16 psi (0.8-1.1 bar) 45 mil: 15-20 psi (1.0-1.4 bar) 62 and 80 mil: 15-25 psi (1.0-1.7 bar)
Design Pressure Drop Per Vessel (3 in series):	30 mil: 36-45 psi (2.5-3.1 bar) 45 mil: 45-60 psi (3.1-4.1 bar) 62 and 80 mil: 45-75 psi (3.1-5.2 bar)
Design Pressure Drop Per Vessel (4 in series):	30 mil: 48-60 psi (3.3-4.1 bar) 45 mil: 60-68 psi (4.1-4.7 bar)
Maximum Pressure Drop above 140°F (60°C):	15 psi (1.0 bar) between 60-69°C (140-157°F) 13 psi (0.9 bar) between 70-79°C (158-175°F) 10 psi (0.7 bar) between 80-85°C (176-185°F)

* Consult KMS Process Technology Group for specific applications.

NOMINAL DIMENSIONS



Model	A		B		C	
	inches	(mm)	inches	(mm)	inches	(mm)
3838	38.0	(965)	3.8	(96)	0.831	(21.1)
4336	35.5	(902)	4.3	(109)	0.831	(21.1)
6438	38.0	(965)	6.4	(162)	1.138	(28.9)
8038	38.0	(965)	7.9	(201)	1.138	(28.9)

HpHT HFK-131 and HFK-328 SPIRAL ELEMENTS

Membrane Characteristics:

- The membrane used in the HpHT UF elements consists of a semipermeable polyethersulfone (PES) layer on a polyolefin backing material.

Operating Limits:

- **Operating Pressure:** Maximum operating pressure is listed on the first page of this document. Actual operating pressure is dependent upon system flux rate (application specific) as well as feed, concentration and temperature conditions.
- **Permeate Pressure:** Permeate pressure should not exceed baseline (concentrate) pressure at any time (including on-line, off-line and during transition). Reverse pressure will damage the membrane.
- **Differential Pressure:** The maximum differential pressures per element are listed on the front of this document, including design values for multi-element housings.
- **Temperature:** Maximum operating and cleaning temperatures for the HpHT elements are shown on the first page of this document. Above 60°C (140°F) temperature change should not exceed 5°C (9°F) per minute.
- **pH:** Allowable range for continuous operation and cleaning is shown on the first page of this document.

Water Quality for Cleaning & Diafiltration:

- **Turbidity and SDI:** Maximum feed turbidity is 1 NTU. Maximum feed SDI is 5.0 (15-minute test).
- **Guidelines:** Please refer to the KMS "Water Quality Guidelines for CIP and Diafiltration" for more detailed information.

Chlorine and Chemical Exposure:

- Adherence to cleaning and sanitizing procedures including chemical concentrations, pH, temperature, and exposure time is necessary to achieve maximum useful element life. Accurate records must be maintained.
- KMS standard cleaning procedures for the specific applications should be followed. Recommended chlorine exposure time at the defined conditions is 30 minutes per day.
- Residual chlorine concentration during cleaning cycle (CIP) should be 150 ppm @ pH 10.5-11.0. Chlorine concentration should never exceed 200 ppm.

- Chlorine should only be added to the cleaning solution after the pH has been adjusted to 10.5-11.0.
- Iron or other catalyzing metals in the presence of free chlorine or hydrogen peroxide will accelerate membrane degradation.
- Sanitizing should be done only after a complete cleaning cycle and with water of acceptable quality. Refer to cleaning instructions and feedwater quality technical bulletins.

Cationic Polymers and Surfactants:

HpHT UF membranes may be irreversibly fouled if exposed to cationic (positively charged) polymers or surfactants. Exposure to these chemicals during operation or cleaning is not recommended and will void the warranty.

Lubricants:

For element installation, use only water or glycerin to lubricate seals. The use of petroleum or vegetable-based oils or solvents may damage the element and will void the warranty.

Supplemental Technical Bulletins:

- UF Element Cleaning Procedures
- Water Quality Guidelines for CIP and Diafiltration
- HpHT Element Cleaning Procedures

KMS ASSIST® Service and Ongoing Technical Support:

KMS has an experienced staff of professionals available to assist end-users and OEM's for optimization of existing systems and support for the development of new applications. KMS also offers a complete line of KOCHKLEEN® membrane pretreatment, cleaning, and maintenance chemicals.

KMS Capability

KMS is the leader in crossflow membrane technology, manufacturing reverse osmosis, nanofiltration, microfiltration, and ultrafiltration membranes and membrane systems. The industries we serve include food, dairy and beverage, semiconductors, automotive, water and wastewater, chemical and general manufacturing. KMS adds value by providing top quality membrane products and by sharing our experience in the design and supply of thousands of crossflow membrane systems worldwide.

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For related trademark information, visit www.kochmembrane.com/legal

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